## Amendments to the claims:

## Claims 11-14 are cancelled.

## Claims 46, 49 and 52 are amended.

## 1.-5. (Cancelled)

1	6. (Previously Presented) A spin valve transistor comprising:
2	an emitter;
3	a collector;
4	a base between the emitter and the collector;
5	a spin valve including:
6	a ferromagnetic free layer structure;
7	a self-pinned antiparallel (AP) pinned layer structure without any pinning structure
8	pinning the self-pinned AP pinned layer structure; and
9	a nonmagnetic spacer layer between the free layer structure and the AP pinned layer
10	structure; and
11	the base comprising at least said free layer structure;
12	the self pinned AP pinned layer structure comprising:
13	a ferromagnetic first antiparallel (AP) pinned layer;
14	a ferromagnetic second antiparallel (AP) pinned layer;
15	a nonmagnetic antiparallel coupling (APC) layer located between the first and
16	second AP pinned layers;
17	one of the first and second AP pinned layers having a cobalt iron (CoFe) film with
18	a positive magnetostriction;
19	the CoFe film having a magnetostrictive anisotropy field that is oriented
20	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned
21	layer structure; and
22	the first and second AP pinned layers having the same magnetic thickness.

1	7. (Previously Presented) A spin valve transistor comprising:
2	an emitter;
3	a collector;
4	a base between the emitter and the collector;
5	a spin valve including:
6	a ferromagnetic free layer structure composed of iron (Fe);
7	a self-pinned antiparallel (AP) pinned layer structure;
8	a nonmagnetic spacer layer between the free layer structure and the AP pinned layer
9	structure; and
10	the free layer structure interfacing the spacer layer;
11	the base comprising at least said free layer structure;
12	the self pinned AP pinned layer structure including:
13	a ferromagnetic first antiparallel (AP) pinned layer;
14	a ferromagnetic second antiparallel (AP) pinned layer; and
15	a nonmagnetic antiparallel coupling (APC) layer located between the first and
16	second AP pinned layers;
17	the first AP pinned layer being composed of iron (Fe) and interfacing the spacer layer;
18	the second AP pinned layer including:
19	an iron (Fe) film;
20	a cobalt iron (CoFe) film with a positive magnetostriction;
21	the iron (Fe) film being located between and interfacing the APC layer and the
22	cobalt iron (CoFe) film; and
23	the CoFe film having a magnetostrictive anisotropy field that is oriented
24	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned
25	layer structure.
1	8. (Original) A spin valve transistor as claimed in claim 7 wherein the cobalt iron
2	is $Co_{90-50}Fe_{10-50}$ .
1	9. (Previously Presented) A spin valve transistor as claimed in claim 7 wherein the
2	cobalt iron (CoFe) film is Co <sub>50</sub> Fe <sub>50</sub> .

1	10. (Original) A spin valve transistor as claimed in claim 9 wherein the first and
2	second AP pinned layers have the same magnetic thickness.
	11 15. (Cancelled)
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1	16. (Previously Presented) A magnetic head assembly comprising:
2	a write head;
3	a read head adjacent the write head;
4	the read head including:
5	ferromagnetic first and second shield layers; and
6	a spin valve transistor located between the first and second shield layers;
7	the spin valve transistor comprising:
8	an emitter;
9	a collector;
10	a base between the emitter and the collector;
11	a spin valve including:
12	a ferromagnetic free layer structure;
13	a self-pinned antiparallel (AP) pinned layer structure without any pinning
14	structure pinning the self-pinned AP pinned layer structure;
15	a nonmagnetic spacer layer between the free layer structure and the AP
16	pinned layer structure; and
17	the base comprising at least said free layer structure;
18	the self pinned AP pinned layer structure comprising:
19	a ferromagnetic first antiparallel (AP) pinned layer;
20	a ferromagnetic second antiparallel (AP) pinned layer;
21	a nonmagnetic antiparallel coupling (APC) layer located between the first and
22	second AP pinned layers;
23	one of the first and second AP pinned layers having a cobalt iron (CoFe) film with
24	a positive magnetostriction;
25	the CoFe film having a magnetostrictive anisotropy field that is oriented
26	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned
27	layer structure; and
28	the first and second AP pinned layers having the same magnetic thickness.

1	17. (Previously Presented) A magnetic head assembly comprising:
2	a write head;
3	a read head adjacent the write head;
4	the read head including:
5	ferromagnetic first and second shield layers; and
6	a spin valve transistor located between the first and second shield layers;
7	the spin valve transistor comprising:
8	an emitter;
9	a collector;
10	a base between the emitter and the collector;
11	a spin valve including:
12	a ferromagnetic free layer structure composed of iron (Fe);
13	a self-pinned antiparallel (AP) pinned layer structure;
14	a nonmagnetic spacer layer between the free layer structure and the AP
15	pinned layer structure; and
16	the free layer structure interfacing the spacer layer;
17	the base comprising at least said free layer structure;
18	the self pinned AP pinned layer structure including:
19	a ferromagnetic first antiparallel (AP) pinned layer;
20	a ferromagnetic second antiparallel (AP) pinned layer; and
21	a nonmagnetic antiparallel coupling (APC) layer located between the first and
22	second AP pinned layers;
23	the first AP pinned layer being composed of iron (Fe) and interfacing the spacer layer;
24	the second AP pinned layer including:
25	an iron (Fe) film;
26	a cobalt iron (CoFe) film with a positive magnetostriction;
27	the iron (Fe) film being located between and interfacing the APC layer and the
28	cobalt iron (CoFe) film; and
29	the CoFe film having a magnetostrictive anisotropy field that is oriented
30	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned
31	layer structure.

1	18. (Previously Presented) A magnetic head assembly as claimed in claim 17 where
2	the cobalt iron is Co <sub>90-50</sub> Fe <sub>10-50</sub> .
1	19. (Previously Presented) A magnetic head assembly as claimed in claim 17 where
2	the cobalt iron is Co <sub>50</sub> Fe <sub>50</sub> .
1	20. (Original) A magnetic head assembly as claimed in claim 19 wherein the fir
2	and second AP pinned layers have the same magnetic thickness.
1	21. (Withdrawn) A magnetic head assembly as claimed in claim 16 further
2	comprising:
3	the second AP pinned layer being composed of iron (Fe);
4	the first AP pinned layer including:
5	first and second iron (Fe) films with the first iron (Fe) film interfacing the space
6	layer;
7	said cobalt iron (CoFe) film; and
8	the cobalt iron (CoFe) film being located between and interfacing the first an
9	second iron (Fe) film.
1	22. (Withdrawn) A magnetic head assembly as claimed in claim 21 wherein the
2	cobalt iron film is Co <sub>90-50</sub> Fe <sub>10-50</sub> .
1	23. (Withdrawn) A magnetic head assembly as claimed in claim 22 wherein the coba
2	iron film is Co <sub>50</sub> Fe <sub>50</sub> .
1	24. (Withdrawn) A magnetic head assembly as claimed in claim 23 wherein the fir
2	and second AP pinned layers have the same magnetic thickness.
	25. (Cancelled)

1	26. (Previously Presented) A magnetic disk drive comprising:
2	at least one magnetic head assembly that has a head surface;
3	the magnetic head assembly having a write head and a read head;
4	the read head including:
5	ferromagnetic first and second shield layers; and
6	a spin valve transistor located between the first and second shield layers;
7	the spin valve transistor comprising:
8	an emitter;
9	a collector;
10	a base between the emitter and the collector;
1	a spin valve including:
12	a ferromagnetic free layer structure;
13	a self-pinned antiparallel (AP) pinned layer structure without any pinning structure
14	pinning the self-pinned AP pinned layer structure;
15	a nonmagnetic spacer layer between the free layer structure and the AP pinned layer
16	structure; and
17	the base comprising at least said free layer structure;
18	the self pinned AP pinned layer structure comprising:
19	a ferromagnetic first antiparallel (AP) pinned layer;
20	a ferromagnetic second antiparallel (AP) pinned layer;
21	a nonmagnetic antiparallel coupling (APC) layer located between the first and
22	second AP pinned layers;
23	one of the first and second AP pinned layers having a cobalt iron (CoFe) film with
24	a positive magnetostriction;
25	the CoFe film having a magnetostrictive anisotropy field that is oriented
26	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned
27	layer structure; and
28	the first and second AP pinned layers having the same magnetic thickness;
29	a housing;
30	a magnetic medium supported in the housing;

31	a support mounted in the housing for supporting the magnetic head assembly with said head
32	surface facing the magnetic medium so that the magnetic head assembly is in a transducing
33	relationship with the magnetic medium;
34	a motor for moving the magnetic medium; and
35	a processor connected to the magnetic head assembly and to the motor for exchanging
36	signals with the magnetic head assembly and for controlling movement of the magnetic medium.
1	27. (Previously Presented) A magnetic disk drive comprising:
2	at least one magnetic head assembly that has a head surface;
3	the magnetic head assembly having a write head and a read head;
4	the read head including:
5	ferromagnetic first and second shield layers; and
6	a spin valve transistor located between the first and second shield layers;
7	the spin valve transistor comprising:
8	an emitter;
9	a collector;
10	a base between the emitter and the collector;
11	a spin valve including:
12	a ferromagnetic free layer structure composed of iron (Fe);
13	a self-pinned antiparallel (AP) pinned layer structure;
14	a nonmagnetic spacer layer between the free layer structure and the AP pinned layer
15	structure; and
16	the free layer structure interfacing the spacer layer;
17	the base comprising at least said free layer structure;
18	the self pinned AP pinned layer structure including:
19	a ferromagnetic first antiparallel (AP) pinned layer;
20	a ferromagnetic second antiparallel (AP) pinned layer; and
21	a nonmagnetic antiparallel coupling (APC) layer located between the first and
22	second AP pinned layers;
23	the first AP pinned layer being composed of iron (Fe) and interfacing the spacer layer;
24	the second AP pinned layer including:
25	an iron (Fe) film with a positive magnetostriction;

20	a copait iron (Core) film;
27	the iron (Fe) film being located between and interfacing the APC layer and the
28	cobalt iron (CoFe) film; and
29	the CoFe film having a magnetostrictive anisotropy field that is oriented
30	perpendicular to a head surface of the spin valve transistor for self pinning the AP pinned
31	layer structure;
32	a housing;
33	a magnetic medium supported in the housing;
34	a support mounted in the housing for supporting the magnetic head assembly with said head
35	surface facing the magnetic medium so that the magnetic head assembly is in a transducing
36	relationship with the magnetic medium;
37	a motor for moving the magnetic medium; and
38	a processor connected to the magnetic head assembly and to the motor for exchanging
39	signals with the magnetic head assembly and for controlling movement of the magnetic medium.
1	28. (Original) A magnetic disk drive as claimed in claim 27 wherein the cobalt iron
2	is $Co_{90-50}Fe_{10-50}$ .
1	29. (Previously Presented) A magnetic disk drive as claimed in claim 27 wherein the
2	cobalt iron is $Co_{50}Fe_{50}$ .
1	30. (Original) A magnetic disk drive as claimed in claim 29 wherein the first and
2	second AP pinned layers have the same magnetic thickness.
1	31. (Withdrawn) A magnetic disk drive as claimed in claim 26 further comprising:
2	the second AP pinned layer being composed of iron (Fe);
3	the first AP pinned layer including:
4	first and second iron (Fe) films with the first iron (Fe) layer film interfacing the
5	spacer layer;
6	said cobalt iron (CoFe) film; and
7	the cobalt iron (CoFe) film being located between and interfacing the first and
8	second iron (Fe) film

1	32. (Withdrawn) A magnetic disk drive as claimed in claim 31 wherein the co	obalt
2	iron is $Co_{90-50}Fe_{10-50}$ .	
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1	33. (Withdrawn) A magnetic disk drive as claimed in claim 32 wherein the co	obalt
2	iron is $Co_{50}Fe_{50}$ .	
1	34. (Withdrawn) A magnetic disk drive as claimed in claim 33 wherein the firs	t and
2	second AP pinned layers have the same magnetic thickness.	
1	35. (Previously Presented) A spin valve transistor as claimed in claim 9 wherei	n the
2	base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer l	
1	36. (Previously Presented) A spin valve transistor as claimed in claim 35 fu	rther
2	comprising a barrier layer located between the emitter and the base for conducting hot electrons	odes
3	from the emitter to the base wherein the hot electrons have an energy level above Fermi leve	els of
4	the layers in said base.	
1	37. (Previously Presented) A spin valve transistor as claimed in claim 36 wh	erein
2	the first and second AP pinned layers have the same magnetic thickness.	
1	38. (Previously Presented) A magnetic head assembly as claimed in claim	n 19
2	wherein the base further comprises the self-pinned antiparallel (AP) pinned layer structure an	d the
3	spacer layer.	
1	39. (Previously Presented) A magnetic head assembly as claimed in claim 38 ft	ırthei
2	comprising a barrier layer located between the emitter and the base for conducting hot electrons	odes
3	from the emitter to the base wherein the hot electrons have an energy level above Fermi leve	els of
4	the layers in said base.	

(Previously Presented) A magnetic head assembly as claimed in claim 39

wherein the first and second AP pinned layers have the same magnetic thickness.

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41. (Previously Presented) A magnetic disk drive as claimed in claim 29 wherein the base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.

- 42. (Previously Presented) A magnetic disk drive as claimed in claim 41 further comprising a barrier layer located between the emitter and the base for conducting hot electrodes from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.
- 1 43. (Previously Presented) A magnetic disk drive as claimed in claim 42 wherein the 2 first and second AP pinned layers have the same magnetic thickness.
  - 44. (Previously Presented) A spin valve transistor as claimed in claim 6 wherein at least one of the AP pinned layers is  $Co_{50}Fe_{50}$ .
  - 45. (Previously Presented) A spin valve transistor as claimed in claim 44 wherein the base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.
  - 46. (Currently Amended) A spin valve transistor as claimed in claim 45 further comprising a barrier layer located between the emitter and the base for conducting hot electrodes electrons from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.
  - 47. (Previously Presented) A magnetic head assembly as claimed in claim 16 wherein at least one of the AP pinned layers is  $Co_{50}Fe_{50}$ .
  - 48. (Previously Presented) A magnetic head assembly as claimed in claim 47 wherein the base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.

49. (Currently Amended) A magnetic head assembly as claimed in claim 48 further comprising a barrier layer located between the emitter and the base for conducting hot electrodes electrons from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.

- 50. (Previously Presented) A magnetic disk drive as claimed in claim 26 wherein at least one of the AP pinned layers is  $Co_{50}Fe_{50}$ .
  - 51. (Previously Presented) A magnetic disk drive as claimed in claim 50 wherein the base further comprises the self-pinned antiparallel (AP) pinned layer structure and the spacer layer.
  - 52. (Currently Amended) A magnetic disk drive as claimed in claim 51 further comprising a barrier layer located between the emitter and the base for conducting hot-electrodes electrons from the emitter to the base wherein the hot electrons have an energy level above Fermi levels of the layers in said base.